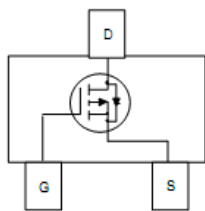
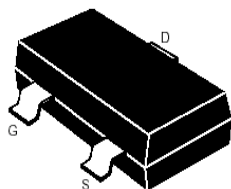


**SOT-23**

**Features**

- Advanced trench process technology
- High Density Cell Design For Ultra Low On-Resistance

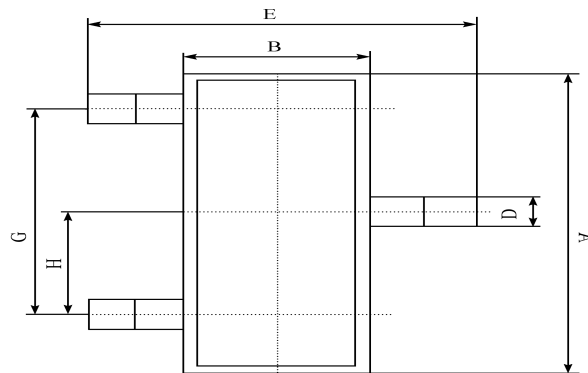
**MAXIMUM RANTINGS**

Characteristic	Symbol	Max	Unit
Drain-Source Voltage	$BV_{DSS}$	-12	V
Gate- Source Voltage	$V_{GS}$	$\pm 8$	V
Drain Current (continuous)	$I_D$	-5.1	A
Drain Current (pulsed)	$I_{DM}$	-20	A
Total Device Dissipation $T_A=25^\circ C$	$P_D$	1250	mW
Junction	$T_J$	150	$^\circ C$
Storage Temperature	$T_{stg}$	-55to+150	$^\circ C$

**Electrical Characteristics**

Characteristic	Symbol	Min	Typ	Max	Unit
Drain-Source Breakdown Voltage ( $I_D = -250\mu A, V_{GS}=0V$ )	$BV_{DSS}$	-12	—	—	V
Gate Threshold Voltage ( $I_D = -250\mu A, V_{GS}=V_{DS}$ )	$V_{GS(th)}$	-0.4	—	-1	V
Diode Forward Voltage Drop ( $I_S = -1 A, V_{GS}=0V$ )	$V_{SD}$	—	—	-1.2	V
Zero Gate Voltage Drain Current ( $V_{GS}=0V, V_{DS}= -12V$ )	$I_{DSS}$	—	—	-1	$\mu A$
Gate Body Leakage ( $V_{GS}=\pm 8V, V_{DS}=0V$ )	$I_{GSS}$	—	—	$\pm 100$	nA
Static Drain-Source On-State Resistance ( $I_D = -5.1A, V_{GS}= -4.5V$ )	$R_{DS(ON)}$	—	28	35	$m\Omega$
Static Drain-Source On-State Resistance ( $I_D = -4.5A, V_{GS}= -2.5V$ )	$R_{DS(ON)}$	—	38	45	$m\Omega$
Static Drain-Source On-State Resistance ( $I_D = -2 A, V_{GS}= -1.8V$ )	$R_{DS(ON)}$	—	50	59	$m\Omega$
Input Capacitance ( $V_{GS}=0V, V_{DS}= -10V, f=1MHz$ )	$C_{ISS}$	—	920	—	pF
Output Capacitance ( $V_{GS}=0V, V_{DS}= -10V, f=1MHz$ )	$C_{OSS}$	—	220	—	pF
Turn-ON Time ( $V_{DS}= -10V, I_D = -2A, R_{GEN}=6\Omega$ )	$t_{(on)}$	—	8	—	ns
Turn-OFF Time ( $V_{DS}= -10V, I_D = -2A, R_{GEN}=6\Omega$ )	$t_{(off)}$	—	60	—	ns

**SOT-23 PACKAGE OUTLINE** Plastic surface mounted package



SOT-23	
A	2.90 ± 0.10
B	1.30 ± 0.10
C	1.00 ± 0.10
D	0.40 ± 0.10
E	2.40 ± 0.20
G	1.90 ± 0.10
H	0.95 ± 0.05
J	0.13 ± 0.05
K	0.00 - 0.10
M	≥ 0.2
N	0.60 ± 0.10
P	7 ± 2°

(UNIT): mm

